



Announcement of artists shortlisted for the 11th Benesse Prize

Singapore, Naoshima, 25 October 2016 – Benesse Holdings, Inc. (Benesse) and Singapore Art Museum (SAM) are pleased to announce the names of the five artists shortlisted for the 11th Benesse Prize (in alphabetical order):

- Martha Atienza, Philippines/ Netherlands
- Bui Cong Khanh, Vietnam
- Ade Darmawan, Indonesia
- Qiu Zhijie, China
- Pannaphan Yodmanee, Thailand

Organised by Benesse, in conjunction with Singapore Biennale 2016 (SB2016) and its main organizer SAM, the 11th edition of the Benesse Prize will award an outstanding SB2016 artist whose art practice embodies an experimental and critical spirit, and for his/her potential to develop a reflection around the theme of “Benesse” (Well-Being). This will be the first time that the Benesse Prize, awarded at the Venice Biennale for the last ten editions, is presented in Asia. The winning artist will be chosen from the short-list by Benesse Holdings and Fukutake Foundation, and the award presentation take place during Singapore Art Week 2017 at SAM. The winning artist will receive a commission to create a work to be exhibited at Benesse Art Site Naoshima, Japan, and a cash prize of JPY 3,000,000 from Benesse.

For more information please refer to the attached media release, or contact:

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